

SIAGON-BASED OXYNITRIDE PHOSPHOR, PROCESS FOR ITS
PRODUCTION, AND USE THEREOF

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ABSTRACT

An α -sialon-based oxynitride phosphor characterized
10 in that the content of α -sialon represented by the
general formula: $M_xSi_{12-(m+n)}Al_{(m+n)}O_nN_{16-n}:Ln_y$ (wherein M is at
least one metal selected from among Li, Ca, Mg, Y or
lanthanide metals excluding La and Ce, Ln is at least one
15 lanthanide metal selected from among Ce, Pr and La or at
least one lanthanide metal selected from among Eu, Dy,
Er, Tb and Yb, $0.3 \leq x+y < 1.5$, $0 < y < 0.7$, $0.3 \leq m < 4.5$, $0 < n < 2.25$,
and $m = ax + by$, where a is the valence of the metal M
and b is the valence of the lanthanide metal Ln), wherein
all or a portion of the metal M dissolved in the α -
20 sialon is replaced with the lanthanide metal Ln as the
luminescence center, is 75 wt% or greater when the
lanthanide metal Ln is at least one lanthanide metal
selected from among Ce, Pr and La and 90 wt% or greater
when the lanthanide metal Ln is at least one lanthanide
25 metal selected from among Eu, Dy, Er, Tb and Yb, and in
that the content of metal impurities other than the metal
M, lanthanide metal Ln, silicon, IIIA elements (aluminum,
gallium), oxygen and nitrogen, is no greater than 0.01
wt%.